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(54) Abstract Title  
**High-purity low-resistivity electrostatic chucks**

(57) The volume resistivity of a body consisting essentially of aluminum nitride is reduced by exposing the body to a soak temperature of at least about 1000°C in an atmosphere deficient in nitrogen, such as an atmosphere consisting essentially of argon. The body can be, for example, a green body of aluminum nitride powder of a densified, or sintered body, such as a polycrystalline body. An electrostatic chuck has an electrode within a chuck body. A first portion of the chuck body, at a first side of the electrode, has a volume resistivity less than about  $1 \times 10^{13}$  ohm.cm at about 23°C. A second portion of the body, at a second side of the electrode, has a volume resistivity within one order of magnitude that of the first portion.

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